

Special Issue

Nanomaterials and Flexible Electronic Devices: Processing, Diagnostics and Applications

Message from the Guest Editors

This Special Issue highlights the latest research and technological innovations in the fields of nanomaterials and flexible electronic devices, addressing their processing, diagnostic techniques, and cutting-edge applications. With rapid advancements in wearable electronics, artificial skin, and smart healthcare systems, flexible electronics have emerged as a transformative technology with a vast market potential. This Special Issue aims to gather high-quality contributions that explore novel materials, advanced fabrication methods, and emerging applications to overcome current limitations in flexibility, durability, and performance.

Guest Editors

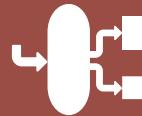
Dr. Yongchao Yu

Dr. Ming Xiao

Dr. Shutong Wang

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Processes
Editorial Office
MDPI, Grosspeteranlage 5
4052 Basel, Switzerland
Tel: +41 61 683 77 34
processes@mdpi.com

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Prof. Dr. Giancarlo Cravotto

Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

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